



RESPONSE UNDER 37. CFR 1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 1755

AF

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Tatsuhiko SHIBUYA et al.

Corres. and Mail
BOX AF

Docket No.00774/98-129 TOK/US

Serial No. 09/302,471

Group Art Unit 1755

Filed April 30, 1999

Examiner D. Brunzman

SILICA-BASED COATING FILM ON
SUBSTRATE AND COATING SOLUTION
THEREFOR

10/a we
5/31/01
B

RESPONSE TO FINAL REJECTION

Assistant Commissioner for Patents,
Washington, D.C.

THE PATENT OFFICE IS AUTHORIZED
TO CHARGE AND DETACHMENT IN THE
FEE FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975.

Sir:

In response to the Final Rejection dated February 27, 2001, please amend the present application as follows:

IN THE CLAIMS:

Please cancel claims 1 to 6 and 16 without prejudice to the subject matter thereof.

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